TiO$_2$-$x$/TiO$_2$-Structure Based ‘Self-Heated’ Sensor for the Determination of Some Reducing Gases

Simonas Ramanavicius$^1$, Alla Tereshchenko$^{2,3}$, Renata Karpicz$^1$, Vilma Ratautaite$^{1,3}$, Urte Bubniene$^{1,3}$, Audrius Maneikis$^1$, Arunas Jagminas$^1$, Arunas Ramanavicius$^{1,3}$*

$^1$ Center for Physical Sciences and Technology, Sauletekio av. 3, LT-10257, Vilnius, Lithuania;
$^2$ Odesa National I.I. Mechnikov University, Department of Experimental Physics, Faculty of Mathematics, Physics and Information Technologies, Pastera 42, 65023, Odesa, Ukraine;
$^3$ Vilnius University, Institute of Chemistry, Faculty of Chemistry and Geosciences, Department of Physical Chemistry, Naugarduko 24, LT-03225 Vilnius, Lithuania.

* Corresponding author: Prof. habil. dr. Arunas Ramanavicius, e-mail: Arunas.Ramanavicius@chf.vu.lt

Abstract

In this research we are reporting gas sensing properties of TiO$_2$-$x$/TiO$_2$-based hetero-structure, which was ‘self-heated’ by current that at constant potential passed through the structure. Amperometric measurements were applied for the evaluation of sensor response towards ethanol, methanol, n-propanol and acetone gases/vapors. The sensitivity towards these gases was based on electrical resistance changes, which were determined by amperometric measurements of current at fixed voltage applied between Pt-based contacts/electrodes deposited on TiO$_2$-$x$/TiO$_2$-based layer. XRD analysis revealed the formation of TiO$_2$-$x$/TiO$_2$-based hetero-structure, which is mainly based on Ti$_3$O$_5$/TiO$_2$ formed during hydro-thermal oxidation based sensing layer preparation process. Additionally, photoluminescence and time-resolved photoluminescence decay kinetics based signals of this sensing structure revealed the presence of TiO$_2$ mainly in the anatase phase in the TiO$_2$-$x$/TiO$_2$-based hetero-structure, which was formed at 400°C annealing temperature. The evaluation of TiO$_2$-$x$/TiO$_2$-based gas sensing layer was performed at several different temperatures (25°C, 72°C, 150°C, 180°C) and at these temperatures different sensitivity to aforementioned gaseous materials was determined.

Keywords: nonstoichiometric titanium oxides; TiO$_2$-$x$/TiO$_2$; Ti$_3$O$_5$/TiO$_2$; photoluminescence; anatase; rutile; sensor for reducing gases.
Introduction

Among many other inorganic semiconductors-based structures, TiO$_2$-based structures are often used for the development of gas-sensing devices due to their sensing properties [1]. Titanium dioxide (TiO$_2$) is n-type semiconductor, which exists in three main phases (i) anatase, (ii) rutile and (iii) brookite with bandgaps of 3.02, 3.23, and 2.96 eV, respectively [2]. All phases of TiO$_2$ can be relatively easily synthesized and/or converted from each to another by relatively simple thermal treatment (annealing).

Attractiveness of TiO$_2$ has significantly increased when water splitting ability under UV light irradiation has been discovered [3]. The discovery of latter effect facilitated the exploitation of catalytic TiO$_2$ properties in the design of sensors for gases and gaseous materials. Due to remarkable properties, many different TiO$_2$-based structures have found applications in various technological areas including biosensors [4,5] and chemical sensors [6,7,8,9,10].

TiO$_2$-based gas sensors are not expensive and relatively cheap. They mostly require simple analytical signal detection and evaluation systems and offer good sensitivity towards many gases and gaseous materials, including both major types of gases: (i) reducing gases such as H$_2$S, H$_2$, CO, NH$_3$, CH$_3$OH, C$_2$H$_5$OH, and many others volatile organic compounds (VOCs), and (ii) oxidizing gases such as O$_2$, NO$_2$, CO$_2$ [11,12,13]. When TiO$_2$-based sensors are affected by different types of gases (reducing or oxidizing) such sensors generate opposite (positive or negative) current/(electrical resistance)-based response, which depends on the type of the gas. Electrical resistance measurements based registration is one of the simplest analytical signal registration method in comparison to many other analytical techniques, e.g. (i) the determination based on photoluminescence (PL) measurements [14] or (ii) based on more sophisticated potentiodynamic electrical/electrochemical techniques such as impedance spectroscopy [15], etc., which can be applied for analytical signal registration in the case of TiO$_2$-based sensors.

The sensing mechanism of TiO$_2$-based gas sensors is complex and it can be described by the superposition of several multi-step processes: (i) a gas adsorption/desorption on TiO$_2$ surface, which dependently on gas nature is followed by enrichment or depletion of upper layer of TiO$_2$-based structure by electrons, what significantly (ii) changes the conductivity of TiO$_2$-based grains and (iii) the charge transfer between the grains. In these above mentioned processes surface-to-volume ratio of grains, the grain size and Deby length are playing crucial role to the charge transfer ability of TiO$_2$-based layers. Therefore, the formation of nanostructured TiO$_2$ with very high number of grains, i.e. high number of boundaries between grains and increased surface on which gases of interest can be adsorbed, are advantageous for the development of gas sensors.
Actually even the sorption of gases on the surface of TiO$_2$-based structures is not very simple phenomenon, which is mostly based on several different phases, particularly physical-adsorption and chemisorption [21]. During the physical adsorption phase gas molecules (mostly oxygen), which are initially adsorbed on the surface of TiO$_2$ from air, are replaced by molecules of other gases, which are present in gaseous specimen. This process is mainly determined by Van der Waals and electrostatic interactions between TiO$_2$ and the adsorbed gas molecules. During the next phase, adsorbed molecules dependently on their structure and/or orientation on the surface are either attracting or donating electrons to TiO$_2$ surface layer, what induces the variation of conductivity by above mentioned mechanism.

Despite of some recent developments in TiO$_2$-based hetero-structures based sensors, n-type pure TiO$_2$-based gas sensors are characterized by relatively high resistance and relatively poor sensing activity, therefore, various TiO$_2$-based hetero-structures are used instead of pure TiO$_2$. Coupling of TiO$_2$ with various materials can result in increased sensing-ability. The most promising structures are based on coupling of TiO$_2$ with other semiconducting materials, what can increase sensitivity, alternate selectivity, reduce response time, lower operational temperatures in comparison to pure TiO$_2$-based sensors [22,23,24,25,26,27].

One option of modification and/or formation of hetero-structures, which are sensitive to various gaseous materials, is related to the application of conducting polymers such as polypyrrole (Ppy), which is used in order to form TiO$_2$/Ppy-based hetero-structures suitable for the determination of LPG gases such as propane and butane [28]. TiO$_2$/Ppy-based sensors operated at relatively low temperatures, which are close to the room temperature. Some another authors have demonstrated the sensitivity of ultra-thin TiO$_2$/Ppy-based hetero-structures towards NH$_3$ gas [29], which was advanced towards much higher sensitivity by other research team [30]. Advancement in the application of TiO$_2$/Ppy hetero-structures is attributed to the formation of n-p hetero-junctions between TiO$_2$ and Ppy layers. Similar hetero-junctions were reported for TiO$_2$ and another conducting polymer polyaniline (PANI) based hetero-structures TiO$_2$/PANI, which were sensitive towards NH$_3$ [31,32,33,34].

Primary aim of this research is to demonstrate the ability to form layer of TiO$_2$-x/TiO$_2$-based hetero-structures, which will be suitable for the design of gas sensor operating at relatively low temperatures. The next aim was to demonstrate that relatively low resistance of formed TiO$_2$-x/TiO$_2$ layer can be applied for ‘self-heating’ of sensing structure and to evaluate how the selectivity and sensitivity of here designed gas sensor depends on the temperature of TiO$_2$-x/TiO$_2$-based sensing-structure.
**Experimental**

**Formation of TiO$_2$ sample**

Si wafer (1) was oxidized in electric oven with increased concentration of oxygen to form a few micrometres thick oxide (SiO$_2$) layer (2) over the Si wafer. After that the metallic titanium (Ti) layer (3) of 100 nm thickness was sputtered by a magnetron. Amorphous non-stoichiometric titanium oxide (TiO$_{2-x}$) and titanium dioxide (TiO$_2$) based hetero-structure (TiO$_{2-x}$/TiO$_2$) was formed by hydrothermal oxidation of Si/SiO$_2$/Ti-based wafer in aqueous alkaline solution. Finally, platinum (Pt) electrodes/(contact zones) (Fig. 1, section 4) were formed on the top of the crystalline TiO$_2$ by magnetron sputtering.

![Diagram](image.png)

**Figure 1.** A. Schematic view (layer-by-layer) of initial structure, which was used for the design of sensor: 1 – Si-based wafer; 2 – thin layer (100 nm) of SiO$_2$; 3 – thin layer (100 nm) of Ti deposited by magnetron sputtering. B. Schematic view (layer-by-layer) of TiO$_{2-x}$/TiO$_2$-based sensor structure: 1 – Si-based wafer; 2 – thin layer (100 nm) of SiO$_2$; 3 – nonstoichiometric TiO$_{2-x}$/TiO$_2$ layer formed by hydrothermal oxidation; 4 – Pt electrodes/(contact zones) deposited by magnetron sputtering.
The next step in sensor development procedure was based on annealing of Ti-based structures, which was performed at three different temperature regimes:

(i) 50°C/1h + 400°C/2h temperature for the formation of TiO$_2$-x/TiO$_2$(400°C) structure;
(ii) 50°C/1h + 600°C/2h temperature for the formation of TiO$_2$-x/TiO$_2$(600°C) structure;
(iii) 50°C/1h + 800°C/2h temperature for the formation of TiO$_2$-x/TiO$_2$(800°C) structure.

All mentioned procedures enabled to form mixed crystal phase TiO$_2$-x/TiO$_2$-based heterostructures (Fig. 1, layers 4 and 5) at over-layer containing significant amount of TiO$_2$ in the form of anatase and/or rutile phases and TiO$_2$-x, which was formed in the deeper layers of the structure below fully oxidized stoichiometric TiO$_2$.

Finally, platinum-based electrodes were deposited on the formed TiO$_2$-x/TiO$_2$(400°C), TiO$_2$-x/TiO$_2$(600°C) and TiO$_2$-x/TiO$_2$(800°C) layers by magnetron sputtering. The dimensions of structure were: 8 mm – length of the structure and 3 mm – distance between platinum electrodes deposited over TiO$_2$-x/TiO$_2$-based layer. The thickness of formed titanium layer was 100 nm, the measurements were performed at 25°C (room temperature), 72°C, 150°C, 180°C. The humidity of supplied above mentioned gaseous materials containing air stream was constant during all parts of measurements with methanol, ethanol, n-propanol, and acetone vapour: partial pressure of water in the air stream was 3.170 kPa, which corresponds to 100% of relative humidity at 25°C and at 101.325 kPa pressure. During the measurement of signals towards water, initially dry air stream was supplied and mixed with 1170 ppm of H$_2$O containing air stream at corresponding ratio.

Platinum (Pt) contacts were formed by magnetron sputtering using sputter from VSTSER (Tel-Aviv, Israel) in DC regime under Argon (Ar) atmosphere (20 mTorr pressure) using 1" diameter and 99.99% purity Pt target. Contacts geometry was determined by a mask. In order to improve adhesion between TiO$_2$-x/TiO$_2$-based layer and platinum at first a thin (20 nm) titanium (Ti) layer was sputtered on which Pt contacts were formed. Sputtering power for Ti layer formation was 2.55 W/cm$^2$ with the growth of 0.13 nm/s. During the formation of Pt procedure, magnetron power was 3.06 W/cm$^2$, with layer growth of 0.08 nm/s.

**Scanning electron microscopy (SEM) based characterization of formed TiO$_2$-x/TiO$_2$-based hetero-structure**

The structural properties of the obtained TiO$_2$ samples on silicon substrates were determined using a scanning electron microscope (SEM) Helios NanoLab 650 from FEI (Eindhoven, The Netherlands).
XRD characterization of TiO$_{2-x}$/TiO$_2$-structure

The phase composition of thin films was determined by X-ray diffractometer D8 Advanced from Bruker (USA) with grazing-incident X-ray diffraction over a 2θ range of 22°-65° using Cu Kα (=1.5046). Films for XRD investigations were based on: (i) metallic Ti (100 nm) layer deposited over Si substrate covered by 300 nm SiO$_2$ layer (ii) TiO$_{2-x}$/TiO$_2$(400°C) hetero-structure, which was formed by the oxidation of the same metallic Ti layer (mentioned in part ‘i’) according to above presented protocol of hydrothermal oxidation at 400°C.

The diffraction pattern was generated by X-ray beam at grazing incidence angle of 2°. XRD data library ‘CDD Database PDF2010 - PDF-2/Release 2010 RDB’ was applied for the analysis of XRD patterns.

TiO$_2$-powder, which by producer was declared as TiO$_2$ anatase (TiO$_2$ (anatase)) phase, was received from Sigma-Aldrich (St. Louis, United States) and was used as XRD control while was investigated at the same grazing incidence angle of 2° over similar 2θ range of 22°-65°.

Photoluminescence (PL) based characterization of TiO$_{2-x}$/TiO$_2$-structure

Optical properties of TiO$_{2-x}$/TiO$_2$-based hetero-structures deposited on oxidized silicon substrates were investigated by PL studies using Edinburgh-F900 spectrophotometer (Edinburg Instruments Ltd, UK). The photoluminescence spectra of TiO$_{2-x}$/TiO$_2$-based hetero-structures were excited by solid-state laser with an excitation wavelength of 375 nm (the average pulse power was about 0.15 mW/mm$^2$, the pulse duration 70 ps) and photoluminescence was measured in the range of 400 – 700 nm. For comparison, the photoluminescence spectra of similar oxidized silicon substrates were also registered. All fluorescence spectra were corrected accounting the sensitivity of the instrument.

Photoluminescence measurements of ‘self-heated’ structure were performed at different voltages that heated the sensor up to particular temperatures. The exact temperature was followed with a thermocouple attached to the TiO$_{2-x}$/TiO$_2$ hetero-structure.

The position and intensity of the photoluminescence maximum was determined as corresponding characteristics of Gauss function using Origin program.

Determination of analytical signal towards reducing gases by TiO$_{2-x}$/TiO$_2$-structure based sensor

Measurements of current passing through the sensor structure were performed by potentiostat/galvanostat Autolab 30 Eco Chemie GmbH (Utrecht, The Netherlands), which was controlled by NOVA software. TiO$_{2-x}$/TiO$_2$(400°C) sample was investigated under different constant voltages, which were applied by potentiostat on platinum-based electrodes deposited on the TiO$_{2-x}$/TiO$_2$(400°C) layer.
Evaluated gas concentrations were fixed at: 105 ppm for water, 118 ppm for methanol, 53 ppm for ethanol, 18 ppm for n-propanol, 220 ppm for acetone.

**Figure 2.** Representation of typical analytical signal registered by TiO$_{2-x}$/TiO$_2$(400°C)-based structure. It should be noted that $\Delta I$, the duration of signal development and the regeneration of sensor after measurements were different for different gases and different concentrations of those gases.

Electrical resistance of TiO$_{2-x}$/TiO$_2$(400°C)-based gas-sensitive structure decreased due to increased their conductivity, therefore, current passing through TiO$_{2-x}$/TiO$_2$(400°C)-based structure increased. In present research we have registered a variation of current ($\Delta I$) at constant potential. These variations of measured current ($I$) (Fig. 2) were converted into resistance ($R$) of TiO$_{2-x}$/TiO$_2$-based structure according to the Ohms law:

$$ R = \frac{I}{V} \tag{1} $$

where $V$ is applied voltage.

Then relative response ($\Delta R$, %) was calculated as:

$$ \Delta R = 100 \times \frac{R_{\text{final}} - R_{\text{initial}}}{R_{\text{initial}}} \% \tag{2} $$

where $R_{\text{initial}}$ is initial resistance of TiO$_{2-x}$/TiO$_2$(400°C)-based structure calculated from $I_{\text{initial}}$ at baseline, $R_{\text{final}}$ – final resistance calculated from $I_{\text{final}}$ (Fig. 2).

**Determination of electrical resistance variation with temperature**
Measurements of resistance vs temperature, were performed by system based on closed cycle helium cryostat made by Sumitomo Heavy Industries (Tokyo, Japan) combined with RDK-408D 4K cold head and SRDK Series cryocooler and CSA-71A compressor unit. Temperature was controlled by Lakeshore 340 temperature controller (Lake Shore Cryotronics, Inc., Westerville OH, USA). Resistance was measured by Tektronix DMM 4050 multimeter (Tektronix UK Ltd., Bracknell, United Kingdom). This closed cycle helium cryostat was used for measurement of resistance was performed only after exact equilibration of temperature at each selected point in the temperature range from 4.2 K to 300 K, with 5 K intervals between measurement points. Temperature was changed in cyclic manner two ways: black cycles shows points measured by cooling down, red squares shows points by increasing temperature. Measured performed in vacuum 10^{-3} Torr.
Results and Discussion

SEM-based structural characterization of TiO$_{2-x}$/TiO$_2$-based layer

SEM images of TiO$_{2-x}$/TiO$_2$(400°C)-based hetero-structure at different extent s (Figs. 3A, 3B) illustrate that the sample has a highly porous surface with nanostructures in the form of nano-plates and nano-sponges, which significantly enhanced both (i) surface area and (ii) surface to volume ratio of the gas-sensitive area of sensor. Therefore, such formations are very beneficial in order to get increased surface area, which is available for gas adsorption and enhances the sensitivity of such structure.

Figure 3. SEM images of TiO$_{2-x}$/TiO$_2$(400°C)-based hetero-structure at different magnification: A – at ×25000; B – at ×50000.

XRD characterization of TiO$_{2-x}$/TiO$_2$-structure

XRD pattern of metallic Ti (Fig. 4, A$_{\text{metallic Ti}}$), which was observed for initial metallic Ti layer of 100 nm thickness that was formed by magnetron sputtering and was used for further hydrothermal oxidation at 400°C into TiO$_{2-x}$/TiO$_2$(400°C)-based hetero-structure, well represents all characteristic peaks of metallic Ti (according to PDF '00-044-1294 for metallic Ti').

XRD pattern of TiO$_{2-x}$/TiO$_2$(400°C) (Fig. 4, B$_{(\text{TiO}_2-x/\text{TiO}_2\text{-structure})}$) represents relatively high dispersion in TiO$_{2-x}$/TiO$_2$(400°C)-based hetero-structure, but according to Fukushima et al. [35] even the presence of broad ‘peak area’ in titanium oxide based pattern between 27° and 37° can be assigned to the presence of Ti$_3$O$_5$, Ti$_5$O$_7$ and/or Ti$_8$O$_{15}$. Thus, in our research we have observed much better expressed XRD peak between 34° and 37° (Fig. 4, Inset, area $I$), which is in good agreement with $\gamma$-Ti$_3$O$_5$ reported in the PDF ‘00-040-0806 for $\gamma$-Ti$_3$O$_5$’ and also in relatively good agreement with XRD pattern presented by Yoshimatsu et al. [36] for $\gamma$-Ti$_3$O$_5$ formed by pulsed
laser deposition. Results obtained by Yoshimatsu et al. [36] showed low-temperature superconductivity in both Ti$_4$O$_7$ and $\gamma$-Ti$_3$O$_5$ films. In addition, these authors reported relatively broad XRD peaks at 36-38° for $\gamma$-Ti$_3$O$_5$ and at 42-43° for Ti$_4$O$_7$. The peak observed in our research (Fig. 4, B$_{\text{(TiO}_2\text{-x/TiO}_2\text{-structure)}}$ and Inset, area -1) according to the shape-like-features and signal to noise ratio is very similar to that at 36-38° for $\gamma$-Ti$_3$O$_5$, just some shift is observed because preparation procedures of both films were very different, therefore, the composition and stoichiometry of both here discussed TiO$_{2-x}$-based structures can be different at some extent.

Another broad peak area (Fig. 4, Inset, area 2) between 36° and 39° is assigned to TiO$_2$(anatase) according to PDF ‘01-075-2545 for TiO$_2$(anatase)’ and control XRD pattern (Fig. 4, C$_{\text{(TiO}_2\text{ powder)}}$) registered at the same experimental conditions for TiO$_2$(anatase) powder purchased from Sigma Aldrich, where according to match between XRD patterns (Fig. 4, C$_{\text{(TiO}_2\text{ powder)}}$) with PDF ‘01-089-0552 for TiO$_2$(rutile)’ we have detected the presence of some TiO$_2$(rutile) phase.

**Figure 4.** XRD patterns of: A$_{\text{(metallic Ti)}}$ – metallic Ti layer of 100 nm thickness, which was formed by magnetron sputtering; B$_{\text{(TiO}_2\text{-x/TiO}_2\text{-structure)}}$ – TiO$_2\text{-x/TiO}_2$(400°C)-based hetero-structure, which was formed from above mentioned metallic 100 nm thick Ti layer; C$_{\text{(TiO}_2\text{ powder)}}$ – TiO$_2$-powder, which was used as ‘control sample’ and by supplier (Sigma-Aldrich) was declared as 99.3% TiO$_2$ in anatase phase.
Titanium pentoxide (Ti$_3$O$_5$) with polymorphisms (α-, β−, γ−, δ−, and λ-phases) is ‘a close neighbour’ of the Magnéli phase [37,38,39,40,41], and sometimes it is designated as the first member of the Magnéli phase, because their chemical formula is consistent with that of the Magnéli phase (Ti$_{2n-1}$O$_n$ at $n = 3$). According to PDF ‘00-040-0806 for γ-Ti$_3$O$_5$’ Ti$_3$O$_5$ possess a monoclinic cell (a = 9.9701 Å, b = 5.0747 Å, c = 7.1810 Å, $\beta$ = 109.865°), which is superconducting at low temperatures (below 3 K) similarly to Ti$_4$O$_7$-based Magnéli phase [36]. Differently from the ‘most respectful’ member of Magnéli phase – Ti$_4$O$_7$, which in crystal structure is having TiO$_2$-rutile-based shear planes [42,43], in Ti$_3$O$_5$ there are no such TiO$_2$-rutile based shear planes [36]. Therefore, in our XRD patterns we are observing only signs of M$_3$O$_5$ and TiO$_2$-(anatase) without any presence of rutile. Such composition was formed because for the formation of TiO$_2$-x/TiO$_2$-based hetero-structures we have applied 400°C temperature at which the formation of M$_3$O$_5$-TiO$_2$-(anatase) ‘intergrowths’ is observed, as it has been reported and investigated by other research teams [44] and very recently has been confirmed by some other research group at different conditions [45]. The formation of above mentioned M$_3$O$_5$-TiO$_2$-(anatase) ‘intergrowths’ is in well agreement with our results based on photoluminescence (Figs. 5A) and photoluminescence-decay (Fig. 5D) measurements, which are discussed in the next chapter, where we are clearly observing effects induced by the presence of TiO$_2$-(anatase)-

**Photoluminescence properties of hybrid TiO$_2$-x/TiO$_2$-based structures**

All photoluminescence spectra of the evaluated TiO$_2$-x/TiO$_2$-based structures were characterized by a wide photoluminescence maximum in the region of wavelengths between 415-500 nm. However, the quality of the photoluminescence signal of all three TiO$_2$-x/TiO$_2$-based structures was of great difference. As it is demonstrated in the Figure 5, this depends on the temperature that is applied for the annealing of TiO$_2$-x/TiO$_2$-based structures, because at different temperatures different phases of TiO$_2$ on the surface of TiO$_2$-x/TiO$_2$-based structures were formed. TiO$_2$-x/TiO$_2$(400°C) structure, which was formed by annealing at 400°C, generated the most intense photoluminescence signal (Fig. 5A). The upper layer generates the strongest photoluminescence signal and the spectrum of TiO$_2$-x/TiO$_2$(400°C) is characterized by photoluminescence peaks, which are observed at 415, 440, 470 nm of the main photoluminescence band (Fig. 5A). These photoluminescence peaks reveal the presence of TiO$_2$-(anatase) in TiO$_2$-x/TiO$_2$(400°C) hybrid-structure. TiO$_2$-x/TiO$_2$(600°C) structure, which was formed by annealing at 600°C, also has demonstrated some photoluminescent properties but the photoluminescence signal was about 10
times lower (Fig. 5B) and revealed presence of mixed TiO$_2$(anatase) and TiO$_2$(rutile) structures of TiO$_2$-$x$/TiO$_2$(600°C) sample.

Figure 5. A – Photoluminescence spectra of TiO$_2$-$x$/TiO$_2$(400°C) sample (1), and silicon substrate (2); B – Photoluminescence spectra of TiO$_2$-$x$/TiO$_2$(600°C) sample (1), and silicon substrate (2); C – Photoluminescence spectra of TiO$_2$-$x$/TiO$_2$(800°C) sample; D – Photoluminescence decays of TiO$_2$-$x$/TiO$_2$(400°C) sample at different photoluminescence emissions bands under 375 nm excitation.

TiO$_2$-$x$/TiO$_2$(800°C) structure, which was formed by annealing at 800°C, was characterized by very weak, about 100 times lower photoluminescence signal, than that was observed for TiO$_2$-$x$/TiO$_2$(400°C) sample (Fig. 5C). Thus TiO$_2$-$x$/TiO$_2$(800°C) structure is not suitable for further investigations required for optoelectronic sensors and, as it is revealed by below presented results, this structure was also not suitable for the sensing of gases selected for this research.

TiO$_2$-$x$/TiO$_2$(400°C) structure showed the most interesting and the highest quality photoluminescence signal. Therefore, during the next experiment, which was also based on photoluminescence spectrum registration, this structure was investigated under different constant voltages, which were applied by potentiostat on platinum-based electrodes deposited on the TiO$_2$. 
$x$-TiO$_2$(400°C)-based layer. The plots of photoluminescence spectra (Fig. 6A) vs applied voltage are shown in Figure 6B. The elevated voltage from 1V to 5V, results the decrease of intensity of the main photoluminescence maximum and a small shift of photoluminescence maximum position towards shorter wavelengths.

![Photoluminescence spectra](image1)

Figure 6. A – Photoluminescence spectra of TiO$_{2-x}$/TiO$_2$(400°C)-based sample at different applied voltage; B – The changes in spectral position of photoluminescence maximum vs voltage of TiO$_{2-x}$/TiO$_2$(400°C)-based sample; C – The changes in photoluminescence maximum intensity vs voltage of TiO$_{2-x}$/TiO$_2$(400°C)-based sample; D – The plot of temperature vs voltage of TiO$_{2-x}$/TiO$_2$(400°C)-based sample.

Figures 6B and 6C show the position and the intensity of the photoluminescence maximum, which is changing dependently on voltage applied to TiO$_{2-x}$/TiO$_2$(400°C)-based sample. The position (Fig. 6B) of the photoluminescence maximum was determined as a maximum of Gauss function, which represented the best fitting with registered photoluminescence spectra. At voltage values (from 1V to 5V) tested in this experiment the spectral position of the photoluminescence
maximum ($\lambda_{\text{max}}$) gradually shifts towards the IR region (Fig. 6B). In general, the difference between the positions $\lambda_{\text{max}}$ for TiO$_{2-x}$/TiO$_2$(400°C)-based sample at 0 V and 5 V is about 5 nm. A similar trend related to the decrease in photoluminescence intensity of the main maximum with increasing voltage was observed (Fig. 6C). The decrease of photoluminescence intensity by the increase of applied voltage from 0 V to 5 V has been determined, and it shows that the concentration of photoluminescence emitting centres in TiO$_{2-x}$/TiO$_2$(400°C) hetero-structure is reducing by increasing voltage. The plot of temperature vs voltage of TiO$_{2-x}$/TiO$_2$(400°C)-based sample (Fig. 6D) illustrates almost linear dependence in tested potential interval, which can be predicted from Ohm's law, followed by basic recalculations into the heat released by this system.

Such behavior of the photoluminescence spectra vs applied voltage can be caused by an increased sample temperature, which is dependent on electrical current flowing through TiO$_{2-x}$/TiO$_2$(400°C)-based hetero-structure. Thus, a rapid decrease in the photoluminescence intensity of TiO$_2$ with an increase in voltage at $U \geq 6$ V is related to the increase of the sample temperature, which leads to the temperature-based quenching of photoluminescence of TiO$_2$(anatase) [46, 47, 48]. Photoluminescence studies of nanostructured TiO$_2$ at room-temperature were reported in some other researches: (i) the photoluminescence of TiO$_2$(anatase) colloidal particles of different sizes occurs from the shallow trap levels, which are located between 0.41 and 0.64 eV below the conduction band [49]; (ii) the narrow photoluminescence emission bands of TiO$_2$(anatase) powder, which originated from the self-trapped exciton emission (STE) in crystalline TiO$_2$(anatase) containing TiO$_6$ octahedral sheets based structures, was reported [50,51]. In addition to registration of photoluminescence spectra, we have measured the photoluminescence decay kinetics for TiO$_{2-x}$/TiO$_2$(400°C)-based hetero-structure at different narrow photoluminescence emission bands (Fig. 5D). The photoluminescence of TiO$_2$(anatase) decay non-exponentially with dominating fast component, which is characterized by a decay of about 0.6 ns. Here presented photoluminescence decay kinetics clearly verifies the self-trapped exciton emission origin of photoluminescence, which from the broad range of non-stoichiometric titanium oxides (TiO$_{2-x}$) and stoichiometric titanium oxides (TiO$_2$) is the most characteristic for crystalline TiO$_2$(anatase) [52].

**Electrical resistance variation with temperature**

Electrical resistance measurements of TiO$_{2-x}$/TiO$_2$-based structure revealed the oxidation of metallic titanium based layer, because by thermal oxidation the resistance of the sample has increased from 0 Ω (for bare Ti-based layer) up to 72 Ω (for formed TiO$_{2-x}$/TiO$_2$-based structure). The increase of resistance together with the shift of photoluminescence signals clearly shows the formation of TiO$_2$ in the phase of anatase and rutile. However, stoichiometric TiO$_2$-based layers
have relatively low electrical conductivity, which is typically of $10^{-10}$ S/m, but it was demonstrated that the conductivity of TiO$_2$-based layers can be significantly increased by heat-based treatment at a high temperature in a reducing gas-based environment [53]. Further investigations revealed the formation of TiO$_{2-x}$/TiO$_2$-based hetero-structures, because only TiO$_2$ based structures have relatively high band-gap and, therefore, they are not well conducting while the presence of TiO$_{2-x}$ in forms of Ti$_2$O$_3$, Ti$_3$O$_5$ and/or Ti$_4$O$_7$ significantly increases the conductivity of such hetero-structures. It should be noted, that an important issue related to TiO$_{2-x}$ conductivity is that these oxides at the stoichiometry of Ti$_n$O$_{2n-1}$ (with $3 < n < 10$) are forming so called Magnéli phases [54], which possess some properties of metallic conductor [55,56]. As it is seen from resistance vs temperature dependence (Fig. 7, area 1), in here reported TiO$_{2-x}$/TiO$_2$-based hetero-structures at temperatures below 150-180 K we have also determined some signs of such transition into metallic conductivity, which is characteristic of presence of Magnéli phases.

![Figure 7](image)

**Figure 7.** Temperature dependence of electrical resistance ($R(T)$) for the TiO$_{2-x}$/TiO$_2$(400°C)-based hetero-structure. Temperature was changed in two ways (indicated by black and red arrows): (i) black cycles shows points measured by cooling down, (ii) red squares shows points by increasing temperature. Measured was performed in vacuum using helium cryostat.
The R(T) dependence (Fig. 7) is roughly temperature independent from 300K down to relatively low temperatures 180-150. Such kind of the R(T) dependence (almost constant R(T) with respect to T with some increase of conductivity when temperature is decreasing) is expected for a heterogeneous mixture of strongly disordered metal/(metal oxide)-based layer, and proves that the TiO2-x/TiO2(400°C)-based hetero-structure is strongly disordered and composed of many randomly oriented nanocrystals and of many different TiO2-x phases and probably even some metal clusters randomly distributed in the volume of TiO2-x/TiO2-based hetero-structures. It is also remarkable that the roughly constant R(T) dependence also exhibits a series of small resistance jumps in a range of a few percent. These resistance jumps might be induced by the metal-semiconductor transitions within the involved Magnéli phases, which is actually a combination of a variety of different TiₙO₂n−1 phases rather than a single phase. Interestingly at 40 K the increase of electrical resistance is observed (Fig. 7, area 2), similar increase, which was followed by the drop of conductivity below 4 K, observed by some other authors [36], which have reported superconductivity in Ti₄O₇ and γ-Ti₃O₅ films. Some earlier researches illustrated that so called Magnéli phases can be observed in TiO2-x-based layers [57] as planes based on TiₙO₂n−1 that are penetrating through a matrix of TiO₂, therefore, this shear plane based on TiₙO₂n−1 structure can be relatively well conducting [55,56]. There are some indications that the conductivity of properly doped or reduced TiO₂, which partly turns into TiₙO₂n−1, at low temperatures is based on n-type conductivity along above mentioned shear planes. Similar conductivity features are exploited in memristor-type devices based on TiO₂, in which electrical resistance is changed by the oxidation/reduction of the TiO2-based layer by applied corresponding potentials [58]. In another research, it has been reported that the Ti³⁺-containing TiO₂-x/TiO₂, has localized oxygen vacancies, which are beneficial for the electron mobility in n-type semiconducting TiO₂-x/TiO₂ structure [59]. We predict that above mentioned oxygen vacancies are offering advanced gas-sensing ability for TiO₂-x/TiO₂ hetero-structure evaluated in our research. The reduction of TiO₂-based layers leads to the formation of non-stoichiometric titanium oxides, which are represented by general formula TiₙO₂n−1 (where n is in the range between 3 and 10 (3 < n<10) and are known as Magnéli phases [54]. In non-stoichiometric titanium dioxide (TiO₂-x) with a low x (0 < x< 0.10), the dominating point defects in the structure are based mainly on Ti³⁺ and Ti⁴⁺ interstitials and on oxygen vacancies [60]. But the Magnéli phases in which x is in the range between 0.10 and 0.34 (0.10 < x< 0.34) extended planar defects and crystallographic shear planes, which are varying according to the oxygen deficiency are observed [61,62]. TiO₂-x/TiO₂-based hetero-structure, which due to the formation of Ti³⁺ has TiₙO₂n−1 doped TiO₂-x clusters (Fig. 1B, 3rd layer) with significantly advanced electrical conductivity, can be synthesized by several different methods: by plasma treatment [63], metallic zinc based reduction [64], high-energy particle bombardment [65], laser irradiation [66].
and some reactions at higher temperatures \[67\]. In addition to these methods, in recent research we have demonstrated that here applied hydro-thermal approach is also suitable for the formation of TiO$_{2-x}$/TiO$_2$-based hetero-structures from initially deposited titanium-based layer. Due to good electrical conductivity and chemical stability above mentioned Magneli phases are applied in variety of applications, e.g.: cathodic protection, batteries, catalyst support for fuel cells, waste and contaminated water treatment \[53,68,69\]. However, the majority of Magneli phases based research has been related to the fabrication of powders \[19,20\], only few attempts to form Magneli phase based fibres of $\sim 250 \mu m$ with tenable conductivity have been reported \[57\]. Differently from these researches we have produced thin layer of TiO$_{2-x}$-based Magneli phases by oxidation of metallic titanium-based layer, which was deposited by magnetron sputtering. However, due to polymorphism of Ti$_3$O$_5$ based difficulties the growth of a single Ti$_3$O$_5$ crystal is still very challenging, therefore physical properties of Ti$_3$O$_5$ are still under debate \[36\]. Only several studies have dealt with the structural phase transitions accompanying metal–insulator transition of Ti$_3$O$_5$, which were induced: (i) by irradiation with visible-light pulses for $\beta \leftrightarrow \lambda$ transition \[40\], (ii) at 450 K temperatures for $\alpha \leftrightarrow \beta$ transition \[37\] and at 240 K temperatures for $\delta \leftrightarrow \gamma$ transition \[38,39,40,41\]. In addition metal–insulator transition around 350 K was reported by Yoshimatsu et al. \[36\]. Such temperature region (240-350-450 K), where the most significant variation of Ti$_3$O$_5$ conductivity was observed, is in good agreement with our recent research, because we clearly observed the variation of conductivity based on the presence/absence of gaseous compounds in temperature region between room temperature (298 K) and 180°C (453 K).

**Gas sensing by TiO$_{2-x}$/TiO$_2$(400°C) hetero-structure based sensor**

Changes of electrical current passing through TiO$_{2-x}$/TiO$_2$-based hetero-structure at fixed potential were evaluated and recalculated into changes of resistance ($\Delta R \%$) using equations 1-2. $\Delta R$ was evaluated as analytical signal of this sensor. Results presented in Figure 8 illustrate that already at room temperature (25°C) sensor shows some sensitivity towards humidity and to all four here evaluated gaseous materials (methanol, ethanol, n-propanol, acetone). But the signals determined amperometrically at constant 0.5 V potential, which was required for the achievement of 25°C, temperature towards humidity and towards all above mentioned gases were very different. In the presence of water, the resistance has decreased, while in the presence of methanol, ethanol, n-propanol and acetone the resistance of sensor has increased. It is observed due to different nature of these compounds. On the surface of TiO$_{2-x}$/TiO$_2$-based structure adsorbed water tends to fill the boundaries between TiO$_{2-x}$ and TiO$_2$ grains and therefore it enhances the conductivity of TiO$_2$. $x$/TiO$_2$-based hetero-structure, while all other materials have much lower conductivity in comparison to species, which they are replacing during physical- and/or chemical-sorption of
methanol, ethanol, n-propanol, acetone. Therefore, the conductivity of TiO$_{2-x}$/TiO$_2$-based structure at some extent decreases (in the range of 1% in comparison to initial conductivity of TiO$_{2-x}$/TiO$_2$-based structure). There are clear indications that sensitivity towards humidity tends to decrease by elevation of temperature from 72°C to 180°C, because at higher temperatures H$_2$O evaporates from the surface of TiO$_{2-x}$/TiO$_2$-based hetero-structure. Similar tendency at 180°C was observed for methanol and ethanol, but for n-propanol and acetone the highest sensitivity was observed at highest here evaluated 180°C temperature, while the best sensitivity towards methanol and ethanol was determined at 150°C and the best selectivity towards methanol was achieved at 72°C.

![Figure 8. The response of TiO$_{2-x}$/TiO$_2$(400°C)-based hetero-structure towards humidity (H$_2$O), methanol, ethanol, n-propanol, and acetone at different temperatures (25-180°C).](image)

Different sensitivities towards various gaseous materials at different temperatures opens the avenue to apply the array based on similar TiO$_{2-x}$/TiO$_2$-based hetero-structures, where between Pt electrodes different constant potential will be applied and this will heat these structures up to different temperatures, where TiO$_{2-x}$/TiO$_2$-based structures will have different sensitivities. Therefore, the read-out signals from such arrays can be evaluated by ANOVA-based approaches and interpreted as analytical signals. With applied ‘self-heating’ of the sensor, the best selectivity towards methanol was achieved at 72°C, for ethanol the temperature was 150°C – 180°C. For n-propanol and acetone signals increase with heating and reaches its maximum at 180°C. Thus TiO$_2$ thin films are the best for methanol detection at 72°C, for ethanol at 150°C and for acetone at 180°C as response to other gases are significantly lower. There are some indications that to all
other here investigated gaseous materials TiO$_{2-x}$/TiO$_2$-based hetero-structures were the most sensitive at even higher temperatures, but these temperatures were not available due to limitations of our experimental set up.

**Figure 9.** The response of TiO$_{2-x}$/TiO$_2$(400°C) hetero-structure towards ethanol, at different temperatures: 1 – 25°C, 2 – 72°C, 3 – 150°C and 4 – 180°C.

Figure 9 represent normalized response ($\Delta R$, %) of TiO$_{2-x}$/TiO$_2$(400°C) hetero-structure towards ethanol at here evaluated four temperatures: 1 – 25°C, 2 – 72°C, 3 – 150°C and 4 – 180°C. At 150°C and 180°C temperatures the limit of detection (LOD) was 2.6 ppm (Fig. 9, lines 3 and 4), while at 72°C it was 5.3 ppm and at room temperature (25°C) it was 10.6 ppm, due to relatively low response in comparison to background noise. The coefficient of variation calculated from 12 measurements at 150°C towards 53 ppm of ethanol, was 8.8%. During the measurements towards different ethanol vapour concentrations steady-state current was achieved within 4-20 seconds, dependently on ethanol concentration (4 s for the lowest measured ethanol concentration and 20 s for the highest measured ethanol concentration). It should be noted that for some here evaluated volatile organic compounds the response of sensing layer was even slower (e.g. towards the highest n-propanol concentration it exceeded 35 s). This fact can be related to: (i) some inertia of gas supply system and (ii) the dimensions of analyte-molecule larger molecules needs some more time to access deeper layers of TiO2-x/TiO2(400°C)-based hetero-structure.
Conclusions and future developments

In this research we have succeeded to form TiO$_{2-x}$/TiO$_2$-based hetero-structure from thin metallic titanium based layer. This structure as a sensing layer was integrated into gas sensor suitable for the determination of some reducing gases. Relatively high conductivity of TiO$_{2-x}$/TiO$_2$-based hetero-structure was exploited for ‘self-heating’ of this sensor. Such ‘self-heating’ is very beneficial for the development of TiO$_{2-x}$/TiO$_2$-based sensors, because only at higher temperatures (from 72°C to 180°C) advanced sensitivity of TiO$_{2-x}$/TiO$_2$-based sensor towards methanol, ethanol, n-propanol and acetone has been achieved. Analytical performance of here proposed sensor can be adjusted by the optimization of TiO$_{2-x}$/TiO$_2$-based sensing structure and analytical signal registration approach, e.g.: different methods of analytical signal registration (e.g. various potentiostatic, potentiodynamic and galvanostatic methods), which at the same time will serve as heating protocols, can be also applied in order to change the sensitivity/selectivity of here proposed TiO$_{2-x}$/TiO$_2$-based hetero-structure. Therefore, after some further investigations it can be applied for the design of sensors with different selectivity and sensitivity.

Despite of some progress in the preparation of TiO$_2$-based materials, practical exploitation of TiO$_2$-based structures self-doped by Ti$_{n}$O$_{2n-1}$-based structures is still very limited, because, according to the best our knowledge, such hetero-structures still have been used for limited number of practical applications. We expect that above mentioned titanium oxide TiO$_{2-x}$/TiO$_2$-based hetero-structures can find more advanced applications in sensing devices, catalysts, electrode materials, energy storage devices, etc. However, better understanding of the structure formed by here proposed procedure and their sensing ability, which will meet the requirements of other specific applications, is still required. In addition, more comprehensive understanding of the transition from conducting metallic titanium-based layer towards semiconducting TiO$_{2-x}$/TiO$_2$-based structure is still crucial in order to achieve desirable semiconducting properties, which are the most optimal for the applications mentioned above. Therefore, these challenges will be on the agenda of our further studies related to the development of TiO$_{2-x}$/TiO$_2$-structure based materials and the application of these structures for practical purposes.

Acknowledgement: This research was partially supported by Ukrainian-Lithuanian Research project “Application of hybrid nanostructures which are based on TiO$_2$ or ZnO and modified by biomolecules, in optoelectronic sensors” Lithuanian Research Council project No P-LU-18-53. Authors are thankful to Assoc. Prof. Dr. Valentina Plausinatiene for possibility to use XRD equipment and valuable consultations.
References


24


60. Seebauer, E. G.; Kratzer, M.C. Charged point defects in semiconductors, Materials Science and Engineering: R: Reports, 2006, 55, 57


